	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L319	6885806	("O.sub.2" or "N.sub.2O" or "NO.sub.2" or CO or "CO.sub.2" or "H.sub.2O" or oxygen or (nitrogen near2 oxide) or nitrous or cobalt)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 15:51
2	BRS	L320	136905	(TMS or trimethyoxysilane or Silane or trime-thyoxysilane or (trime near2 thyoxysilane) or SiH or Si-H)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 15:52
3	BRS	L321	90628	320 and (substrate$3 or wafer$3 or Si or Silicon)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 16:02
4	BRS	L322	390698	(porous or SiOF or (silicon near2 oxy$6))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 15:59
5	BRS	L323	1453	322 same 320 same 319	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 15:55

	Type	L #	Hits	Search Text	DBs	Time Stamp
6	BRS	L325	269	323 same plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 15:56
7	BRS	L327	837	SiOF	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 15:57
8	BRS	L328	391391	(porous or SiOF or (fluorine-doped near3 oxide) or (fluorin$4 near3 oxide) or (silicon near2 oxy-fluori$6) or (fluori$6 near4 silicon))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 16:01
9	BRS	L329	491	328 same 320 same 319	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 16:02
10	BRS	L330	3065094	substrate$3 or wafer$3 or Si or Silicon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 16:03

	Type	L #	Hits	Search Text	DBs	Time Stamp
11	BRS	L331	450	329 and 330	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 16:04
12	BRS	L333	132	329 same plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 16:05
13	BRS	L334	126	333 and 330	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 16:27
14	BRS	L338	4	(TMS or trimethoxysilane) same SiOF	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 17:22
15	BRS	L339	90	(TMS or trimethoxysilane or Si-H$6 or SiH$6) same SiOF	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 17:01

	Type	L #	Hits	Search Text	DBs	Time Stamp
16	BRS	L340	104	(TMS or trimethoxysilane) same (SiOF or porous) *and*	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/17 17:22

(TMS ...) near8 (conformal EY or barrier)

and

(SiOF or porous)

	Type	L #	Hits	Search Text	DBs	Time Stamp
1	BRS	L1	29	(TMS or trimethoxysilane) and SiOF	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 11:26
2	BRS	L4	2563	(TMS or trimethoxysilane or trimethylsilane or (trimethyl near2 silane)) and (SiOF or porous)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 11:27
3	BRS	L5	2420	(TMS or trimethoxysilane or trimethylsilane) and (SiOF or porous)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 11:53
4	BRS	L7	2391	5 not 1	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 11:27
5	BRS	L8	5	((TMS or trimethoxysilane or trimethylsilane) near4 (conformal$4 or barrier)) and (SiOF or porous)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 11:34

	Type	L #	Hits	Search Text	DBs	Time Stamp
6	BRS	L9	17	((TMS or trimethoxysilane or trimethylsilane) near8 (conformal$4 or barrier)) and (SiOF or porous)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 11:34
7	BRS	L10	12	9 not 8	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 11:42
8	BRS	L14	132	(TMS or trimethoxysilane or trimethylsilane) same (SiOF or porous)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/18 11:54

	Type	L #	Hits	Search Text	DBs
1	IS&R	L2	343	(438/762).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
2	IS&R	L3	143	(438/773).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB
3	IS&R	L4	225	(438/775).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB